

High-κ metal oxide thin film by chemical spray pyrolysis : from optimization of material properties to application in thin film transistor = Metallioksiidi õhukesed kiled keemilise pihustuspürolüüsi meetodil : materjali omaduste optimeerimine ja rakendamine õhukesekilelistes transistorides

Oluwabi, Abayomi Titilope 2020 <https://digikogu.taltech.ee/et/Item/4b6d9afd-74d2-40ac-9c12-335d2f608474>
https://www.ester.ee/record=b5362429*est

Properties of ZnO-nanorod/In₂Se₃/CuInSe₂ solar cell and the constituent layers deposited by chemical spray method = Keemilise pihustuse meetodil sadestatud ZnO-nanovarras/In₂Se₃/CuInSe₂ päikesepatarei ja selle koostisosade omadused
Kärber, Erki 2014 https://www.ester.ee/record=b3073760*est